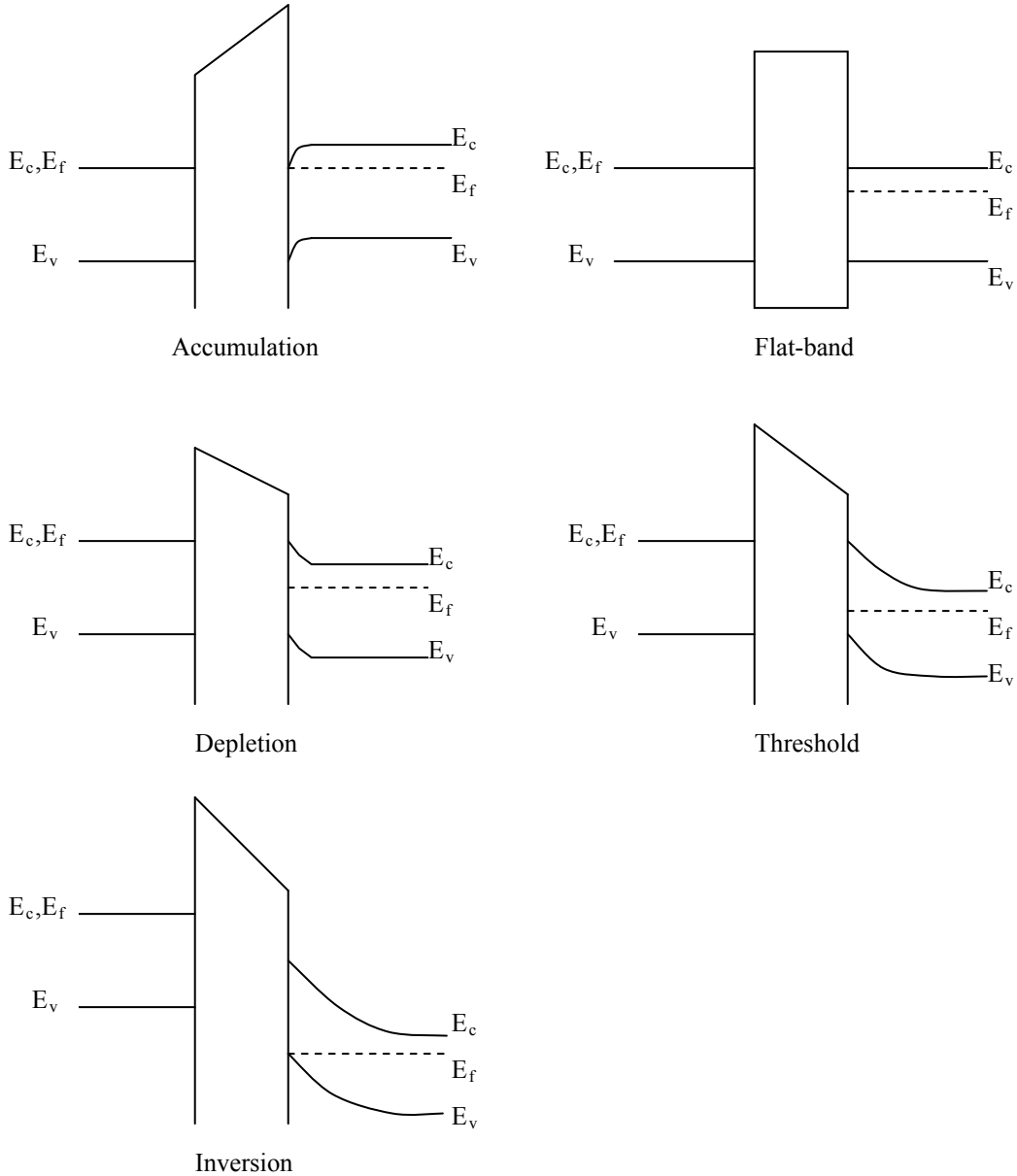


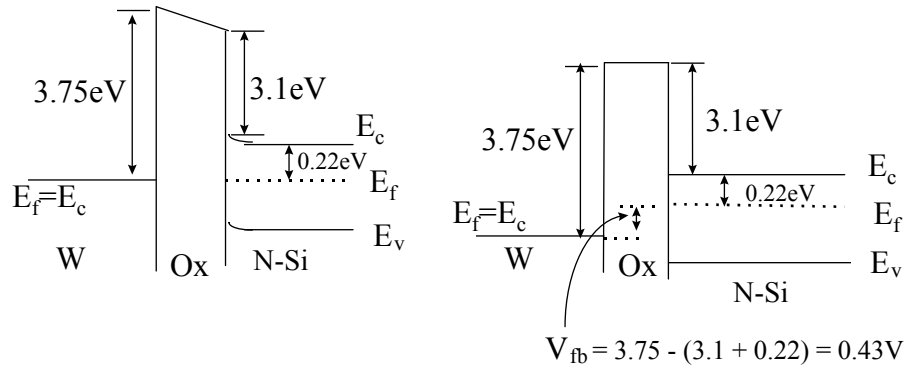
Chapter 5

Energy Band Diagram

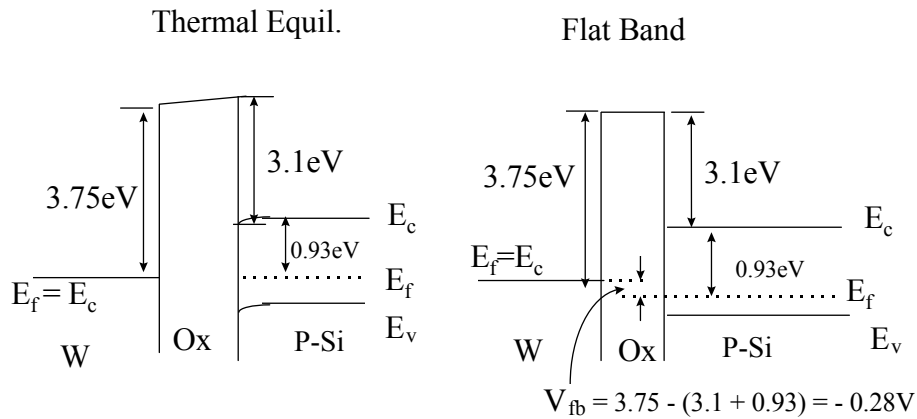
5.1



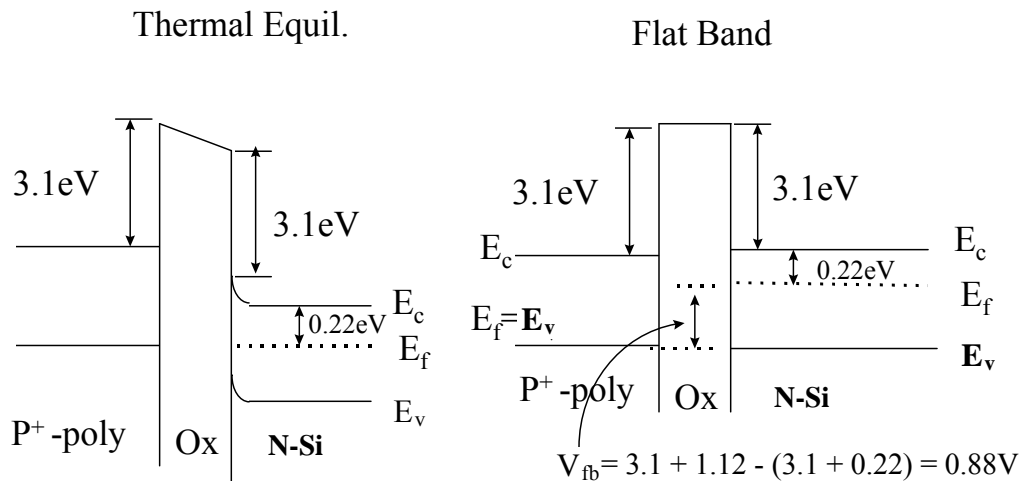
5.2 (a) 1 Ω -cm N-type silicon substrate : $N_d=5 \times 10^{15} \text{ cm}^{-3}$, $E_f = E_c - 0.223 \text{ eV}$



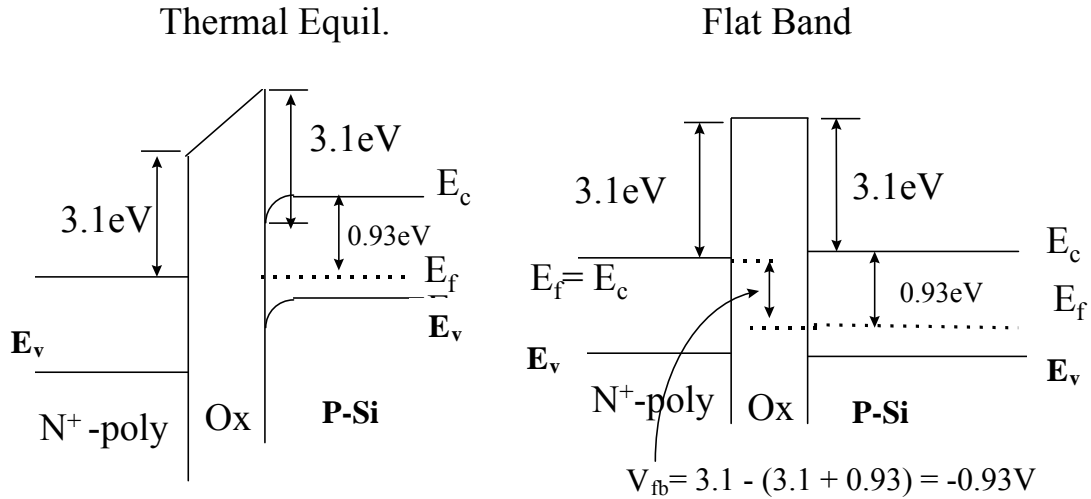
(b) 1 Ω -cm P-type silicon substrate : $N_a=1.5 \times 10^{16} \text{ cm}^{-3}$, $E_f = E_v + 0.168 \text{ eV}$



(c) Heavily doped P^+ -polycrystalline silicon gate with 1 Ω -cm N-type silicon substrate.



- (d) Heavily doped N⁺-polycrystalline silicon gate with 1 $\Omega\text{-cm}$ P-type silicon substrate.



MOS System: Inversion, threshold, depletion, and accumulation

- 5.3** (a) 3
(b) 2
(c) 1
(d) 4
(e) 5

- 5.4** (a)

$$\phi_B = \left(\frac{kT}{q} \right) \ln \left(\frac{N_a}{n_i} \right) = (0.026\text{V}) \times \ln \left(\frac{10^{18}\text{cm}^{-3}}{10^{10}\text{cm}^{-3}} \right) = 0.479\text{V}$$

$$\begin{aligned} \therefore V_{fb} &= \left(\frac{\chi_{si}}{q} \right) - \left[\left(\frac{\chi_{si}}{q} \right) + \frac{1}{2} \left(\frac{E_g}{q} \right) + \phi_B \right] = - \left[\frac{1}{2} \left(\frac{E_g}{q} \right) + \phi_B \right] \\ &= - \frac{1.12\text{V}}{2} - 0.479\text{V} = -1.039\text{V} \end{aligned}$$

- (b)

$$W_{d\max} = \sqrt{\frac{2\epsilon_{si} \times 2\phi_B}{qN_a}} = \sqrt{\frac{2 \times (11.7) \times (8.84 \times 10^{-14}) \times 2 \times (0.479)}{(1.6 \times 10^{-19}) \times (10^{18})}} = 3.521 \times 10^{-6}\text{cm}$$

- (c)

$$\begin{aligned}
V_t &= V_{fb} + 2\phi_B + \frac{\sqrt{2\varepsilon_{si}qN_a \times 2\phi_B}}{C_{ox}} \\
&= (-1.039V) + 2 \times (0.479V) \\
&\quad + \frac{\sqrt{2 \times (11.7) \times (8.85 \times 10^{-14} \text{ F/cm}) \times (1.6 \times 10^{-19} \text{ C}) \times (10^{18} \text{ cm}^{-3}) \times 2 \times (0.479V)}}{(3.9) \times (8.85 \times 10^{-14} \text{ F/cm}) / (2 \times 10^{-7} \text{ cm})} \\
&= 0.2455V
\end{aligned}$$

(d)

Only the flat-band voltage changes.

$$\begin{aligned}
V_{fb} &= \left[\left(\frac{\chi_{si}}{q} \right) + \left(\frac{E_g}{q} \right) \right] - \left[\left(\frac{\chi_{si}}{q} \right) + \frac{1}{2} \left(\frac{E_g}{q} \right) + \phi_B \right] = \frac{1}{2} \left(\frac{E_g}{q} \right) - \phi_B \\
&= \frac{1.12V}{2} - 0.479V = 0.081V \\
\therefore V_t &= (0.081V) + 2 \times (0.479V) \\
&\quad + \frac{\sqrt{2 \times (11.7) \times (8.85 \times 10^{-14} \text{ F/cm}) \times (1.6 \times 10^{-19} \text{ C}) \times (10^{18} \text{ cm}^{-3}) \times 2 \times (0.479V)}}{(3.9) \times (8.85 \times 10^{-14} \text{ F/cm}) / (2 \times 10^{-7} \text{ cm})} \\
&= 1.3655V
\end{aligned}$$

5.5 (a) At $V_g - V_{fb} = -1V$, the MOS capacitor is in accumulation.

$$\begin{aligned}
C_{ox} &= \frac{Q_s}{V_{ox}} = \frac{\varepsilon_{ox}}{T_{ox}} = 4 \times 10^{-7} \frac{F}{cm^2} \\
T_{ox} &= 8.62nm
\end{aligned}$$

(b) At threshold,

$$\begin{aligned}
V_g - V_{fb} = 1V &= \phi_s + V_{ox} = 2\phi_B + \frac{(2\varepsilon_s q N_a 2\phi_B)^{1/2}}{C_{ox}} \quad \text{where} \\
\phi_B &= \frac{kT}{q} \ln \left(\frac{N_a}{n_i} \right).
\end{aligned}$$

Solving iteratively, we get

$$N_a = 2.9 \times 10^{16} \text{ cm}^{-3}.$$

(c) Since $\phi_s \approx 0$, $V_{ox} = -1V$.

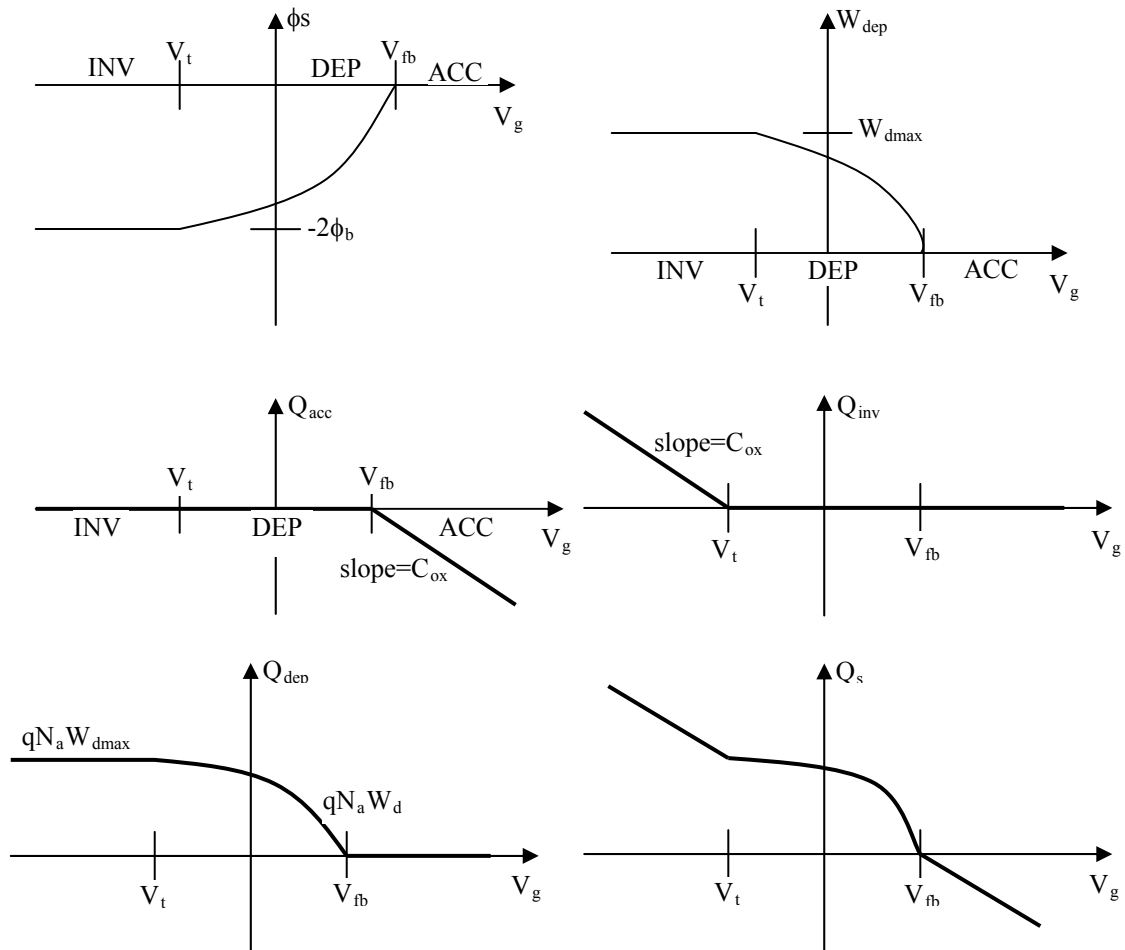
$$(d) \quad V_g - V_{fb} = 1V = \phi_s + V_{ox} = \phi_s + \frac{(2\varepsilon_s q N_a \phi_s)^{1/2}}{C_{ox}}$$

$$\phi_s + 0.245(\phi_s)^{1/2} = 0.5$$

Solving the equations above, we get

$$\phi_s = 0.354V.$$

5.6



5.7 (a) From Equation 5.3.2,

$$V_g = V_{fb} + \phi_s + \frac{1}{C_{ox}} \sqrt{2qN_a \epsilon_s \phi_s} \text{ where } \phi_s = (\sqrt{\phi_s})^2.$$

Rearranging the terms, we obtain

$$\left(\sqrt{\phi_s}\right)^2 + \left(\frac{\sqrt{2qN_a\epsilon_s}}{C_{ox}}\right)\sqrt{\phi_s} + (V_{fb} - V_g) = 0.$$

Solving for $\sqrt{\phi_s}$ yields

$$\sqrt{\phi_s} = \frac{-\frac{\sqrt{2qN_a\epsilon_s}}{C_{ox}} \pm \sqrt{\frac{2qN_a\epsilon_s}{C_{ox}^2} - 4(V_{fb} - V_g)}}{2}.$$

Since $\sqrt{\phi_s}$ cannot be less than 0,

$$\sqrt{\phi_s} = \frac{-\sqrt{2qN_a\epsilon_s}}{2C_{ox}} + \sqrt{\frac{2qN_a\epsilon_s}{4C_{ox}^2} - (V_{fb} - V_g)} = \frac{\gamma}{2} + \sqrt{\frac{\gamma^2}{4} - (V_{fb} - V_g)}$$

where

$$\gamma = \frac{\sqrt{2qN_a\epsilon_s}}{C_{ox}}.$$

Hence,

$$\begin{aligned}\phi_s &= \frac{\gamma^2}{4} + \left[\frac{\gamma^2}{4} - (V_{fb} - V_g)\right] + \frac{\gamma}{2}\sqrt{\frac{\gamma^2}{4} - (V_{fb} - V_g)} \\ &= \frac{\gamma^2}{2} - (V_{fb} - V_g) + \frac{\gamma}{2}\sqrt{\frac{\gamma^2}{4} - (V_{fb} - V_g)}.\end{aligned}$$

Or,

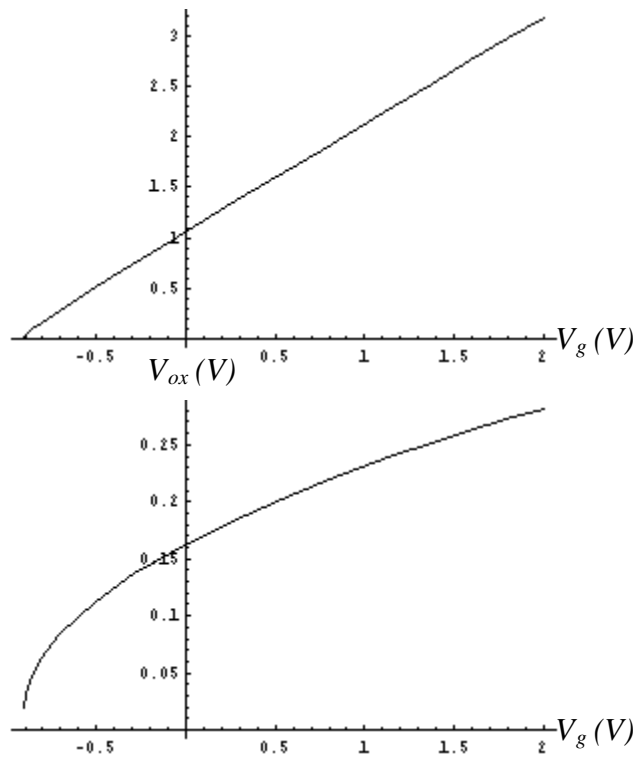
$$\phi_s = \left[\frac{\gamma}{2} + \sqrt{\frac{\gamma^2}{4} - (V_{fb} - V_g)}\right]^2.$$

(b) From Equation 5.3.1,

$$V_{ox} = \frac{\sqrt{2qN_a\epsilon_s}}{C_{ox}}\sqrt{\phi_s} = \gamma\left[\frac{\gamma}{2} + \sqrt{\frac{\gamma^2}{4} - (V_{fb} - V_g)}\right].$$

(c) We can qualitatively predict that $\phi_s \propto V_g$ since $|\gamma| \ll 1$. Also, $V_{ox} \propto \sqrt{V_g}$.

$$\phi_s(V)$$



(d) From Equation 4.2.10,

$$W_{dep} = \frac{\sqrt{2q\epsilon_s}}{C_{ox}} \sqrt{\phi_s} = \frac{\sqrt{2q\epsilon_s}}{C_{ox}} \left[\frac{\gamma}{2} + \sqrt{\frac{\gamma^2}{4} - (V_{fb} - V_g)} \right].$$

5.8 (a) $C_{ox} = \frac{\epsilon_{ox}}{T_{ox}} = 3.45 \times 10^{-7} \frac{F}{cm^2}$

$$\phi_B = kT \ln \frac{N_a}{n_i} = 0.4V$$

$$V_{fb} = -\frac{E_g}{2} - \phi_B = -0.96V$$

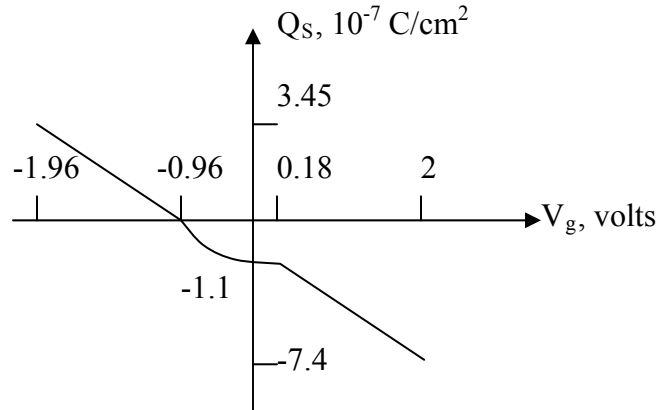
$$V_t = V_{fb} + 2\phi_B + \frac{1}{C_{ox}} \sqrt{2q\epsilon_s N_a 2\phi_B} = (-0.96 + 0.8 + 0.34)V = 0.18V$$

(b) $Q_{acc} = -C_{ox}(V_g - V_{fb}) = 3.45 \times 10^{-7} \frac{C}{cm^2}$

(c) $Q_{dep} = -\sqrt{2q\epsilon_s N_a 2\phi_B} = -1.1 \times 10^{-7} \frac{C}{cm^2}$

$$Q_{inv} = -C_{ox}(V_g - V_t) = -6.3 \times 10^{-7} \frac{C}{cm^2}$$

(d)



5.9

	Parameters	Increase	Decrease	Unchanged
a	Accumulation Region Capacitance			X
b	Flat-band Voltage, V_{fb}	X		
c	Depletion Region Capacitance		X	
d	Threshold Voltage, V_t		X	
e	Inversion Region Capacitance		X	

(a) At accumulation: Accumulation capacitance

$$C = C_{ox} = \epsilon_{ox} / T_{ox}$$

(b) At flat-band: Flat-band Voltage

$$V_{fb} = \phi_g - \left(4.05 + 0.56 + 0.026 \ln \left(\frac{N_a}{n_i} \right) \right)$$

$$N_a \downarrow, \phi_B \downarrow$$

(c) At depletion: Depletion Capacitance

$$1/C = 1/C_{ox} + W_{dep} / \epsilon_s$$

$$N_a \downarrow, W_{dep} \uparrow, C \downarrow$$

(d) At threshold: Threshold Voltage

$$V_t = V_{fb} + |2\phi_B| + Q_d / C_{ox}$$

$$N_a \downarrow, |\phi_B| \downarrow, Q_d \downarrow, V_t \downarrow$$

(e) At inversion: Inversion Capacitance

$$1/C = 1/C_{ox} + W_{d\max} / \epsilon_s$$

$$N_a \downarrow, W_{d\max} \uparrow, C \downarrow$$

5.10 To find the value of the oxide capacitance,

$$C_{ox} = \frac{\epsilon_{ox}}{T_{ox}} = 1.15 \times 10^{-7} \frac{F}{cm^2}.$$

The capacitance at $V_g = V_{fb}$ is given by

$$C_{fb} = \frac{1}{1/C_{ox} + L_D/\epsilon_s} = 7.9 \times 10^{-8} \frac{F}{cm^2}$$

where

$$L_D = \left[\frac{\epsilon_s kT}{q^2 N_a} \right]^{1/2} = 4.09 \times 10^{-6} cm.$$

To find the minimum value of the capacitance,

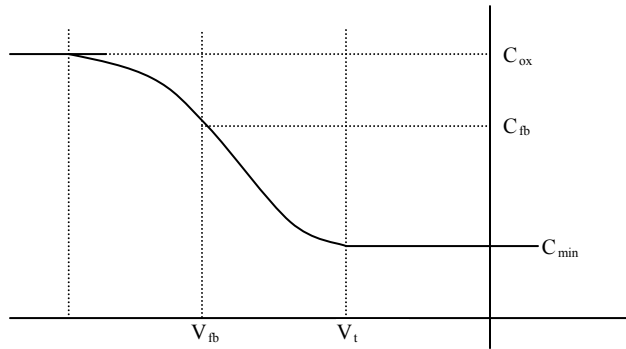
$$W_{d\max} = \sqrt{\frac{4\epsilon_s \phi_B}{qN_a}} = 3 \times 10^{-5} cm ; \phi_B = \frac{kT}{q} \ln \frac{N_a}{n_i} = 0.348V$$

$$C_{\min} = \frac{1}{1/C_{ox} + W_{d\max}/\epsilon_s} = 2.65 \times 10^{-8} \frac{F}{cm^2}.$$

V_t is given by

$$V_t = 2\phi_B + \frac{1}{C_{ox}} \sqrt{2\epsilon_s q N_a 2\phi_B} + V_{fb} = 1.11V$$

where $V_{fb} = \phi_g - \phi_s = -2.00 V$.



To find the effective oxide charge, we need to find

$$\phi_{Al} = 4.1V$$

$$\phi_s = 4.05 + 0.562 + 0.3482 = 4.96V$$

$$\phi_{Al-s} = -0.86V$$

$$\Delta V_t = V_{fb} - \phi_{Al-s} = -2 - (-0.86) = -1.14V = \frac{-Q_{ox}}{C_{ox}}$$

Hence,

$$Q_{ox} = 1.31 \times 10^{-7} \frac{C}{cm^2} = 8.2 \times 10^{11} \frac{q}{cm^2}.$$

Field Threshold Voltage

$$\begin{aligned} 5.11 \text{ (a) } V_{fb} &= \phi_{Al} - \phi_{Si} = 4.1V - (\chi_{Si} + E_g / 2q + \frac{E_i - E_f}{q}) \\ &= 4.1V - (4.05V + (1.12 / 2)V + (kT / q) \cdot \ln(N_a / n_i)) = -0.80V \end{aligned}$$

$$(b) \phi_B = \frac{E_i - E_f}{q} = kT / q \cdot \ln(N_a / n_i) = 0.290V$$

$$W_{d \max} = \sqrt{\frac{2\epsilon_s 2\phi_B}{qN_a}} = 0.866\mu m$$

$$V_t = V_{fb} + 2\phi_B + qN_a W_{d \max} / C_{ox} \geq 5V$$

$$C_{ox} \leq 2.65 \times 10^{-9} F / cm^2$$

$$(c) C_{ox} = \frac{\epsilon}{T_{ox}} = \kappa \epsilon_0 / 1\mu m = 2.65 \times 10^{-9} F / cm^2 \text{ where } K = 2.99$$

(d) In accumulation,

$$V_g - V_{fb} = -1V,$$

$$C_{ox} = Q_s / V_{ox}$$

$$V_t \geq 5V$$

$$C_{ox} \leq 2.65 \times 10^{-9} F / cm^2$$

$$K \leq 2.99$$

It is the maximum allowable K.

$$(e) V_g - V_t = -\frac{Q_{inv}}{C_{ox}}$$

$$Q_{inv} = -C_{ox}(V_g - V_t) = -(2.65 \times 10^{-9} F / cm^2)(2V) = -5.3 \times 10^{-9} C / cm^2$$

$$(f) 1/C = 1/C_{ox} + 1/C_{dep} = 1/C_{ox} + W_{dmax} / \epsilon_s = 1/2.65 \times 10^{-9} F / cm^2 + 0.866 \mu m / \epsilon_s$$

$$C = 2.17 \times 10^{-9} F / cm^2$$

$$(g) V_g = V_{fb} + V_s + V_{ox}$$

$$(V_g \geq V_t) = V_{fb} + 2\phi_B + V_{ox}$$

$$7V = -0.8V + 2(0.29V) + V_{ox}$$

$$V_{ox} = 7.22V$$

Oxide Charge

$$5.12 \Delta V = -Q / C_{ox}$$

$$Q = -C_{ox} \Delta V = -\frac{C_0}{A} \Delta V = -\frac{45 \times 10^{-12}}{6.4 \times 10^{-5}} \times 0.05 = -3.52 \times 10^{-8} C / cm^2$$

$$V_{fb} = \psi_g - \psi_s - Q_f / C_{ox}$$

It should be negative since negative charges increase V_{fb} .

5.13 Oxide charge will change the device characteristics. Mobile charges are particularly bad as they give the device instability. That is, as the charge moves from one side of the oxide to the other, it will change the threshold voltage. This is undesirable.

Mobile charges are generally introduced into the oxide during wafer cleaning or oxidation. Strict measures of cleanliness can be achieved by using ultra-clean chemicals. And, the impurities such as sodium can be immobilized by introducing a chlorine compound during oxidation.

C-V Characteristics

5.14 $V_g = V_{fb} + \phi_s + V_{ox}$

Using $V_{ox} = \frac{qN_a W_d}{C_{ox}}$ and $\phi_s = \frac{W_d^2 q N_a}{2\epsilon_s}$, we solve for W_d

$$V_g - V_{fb} = qN_a \left(\frac{W_d^2}{2\epsilon_s} + \frac{W_d}{C_{ox}} \right)$$

$$W_d = \frac{-2\epsilon_s + \sqrt{4\epsilon_s^2 - 4C_{ox}(2\epsilon_s C_{ox}) \left(\frac{V_g - V_{fb}}{qN_a} \right)}}{2C_{ox}}$$

$$\frac{W_d}{\epsilon_s} = \frac{-1 + \sqrt{1 - \frac{2C_{ox}^2 (V_g - V_{fb})}{q\epsilon_s N_a}}}{C_{ox}}$$

Since $\frac{1}{C} = \frac{1}{C_{ox}} + \frac{1}{C_{dep}} = \frac{1}{C_{ox}} + \frac{W_d}{\epsilon_s}$,

$$\frac{1}{C} = \sqrt{\frac{1}{C_{ox}^2} - \frac{2(V_g - V_{fb})}{q\epsilon_s N_a}}.$$

5.15 (a) The substrate doping is P-type since the threshold voltage is larger than V_{fb} .

(b) $T_{ox} = A \frac{\epsilon_{ox}}{C_{ox}} = \frac{10^{-4} \times 0.345 \times 10^{12}}{50 \times 10^{-12}} = 6.9 \text{ nm}$

(c) $V_t - V_{fb} = 2\phi_B + \frac{\sqrt{2\epsilon_s q N_a 2\phi_B}}{C_{ox}} = 2 \frac{kT}{q} \ln \left(\frac{N_a}{n_i} \right) + \frac{2\sqrt{\epsilon_s q N_a \ln \frac{N_a}{n_i}}}{C_{ox}}$

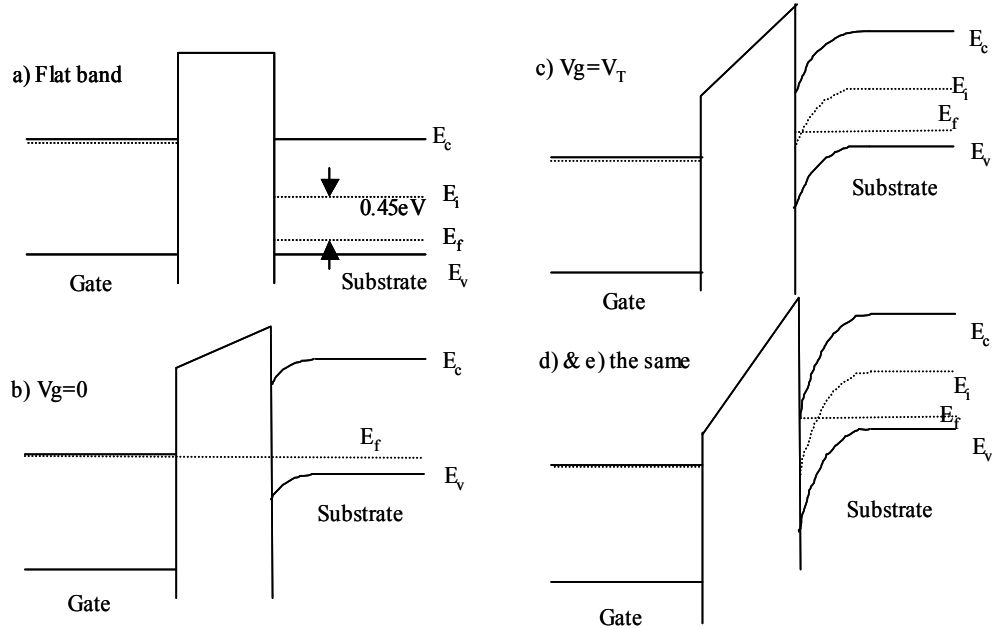
Using $V_{fb} = -1\text{V}$ and $V_t = 0.5\text{V}$ and solving iteratively, we obtain

$$N_a \cong 3 \times 10^{17} \text{ cm}^{-3}.$$

(e) At position C, MOS has the minimum capacitance.

$$C_{\min} = \left(\frac{1}{C_{ox}} + \frac{W_{d\max}}{\epsilon_s} \right)^{-1} = 12.7 \text{ pF} \text{ where } W_{d\max} = \sqrt{\frac{2\epsilon_s}{qN_a} \frac{2kT}{q} \ln \frac{N_a}{n_i}}$$

(e)



$$(f) \quad V_g = 0 = V_{fb} + \phi_s + \frac{1}{C_{ox}} \sqrt{2\epsilon_s q N_a \phi_s}$$

Substituting the numerical values and solving the quadratic equation, we obtain

$$\phi_s + 0.644\sqrt{\phi_s} - 1 = 0$$

$$\phi_s = 0.53V.$$

5.16 (a) P-type, since $V_t > V_{fb}$.

(b) T_{ox} :	A	<u>B</u>	($C_{max} = \epsilon_{ox}/T_{ox}$)
V_{fb} :	A	<u>B</u>	(directly from the graph)
W_{dmax} :		<u>A</u>	B ($1/C_{min} = 1/C_{ox} + W_{dmax}/\epsilon_s$ and $C_{ox}^A > C_{ox}^B$)
N_{sub} :	A	<u>B</u>	($W_{dmax} \sim (N_{sub})^{-1/2}$)
V_t :	A	<u>B</u>	(directly from the graph)

5.17 $A = 100 \times 100 \mu m^2 = 10^{-4} cm^2$

For the MOS capacitor, the field in the oxide $\epsilon_{max} = 8 \times 10^6 = \frac{10V}{T_{ox}}$

$\Rightarrow T_{ox} = 1.25 \times 10^{-6} cm$ or 12.5 nm

$$\therefore C_{ox} = \frac{\epsilon_{ox}}{T_{ox}} A = 28.32 \text{ pF} = C_{MOS}$$

For P⁺N junction,

$$\phi_B = \frac{kT}{q} \ln\left(\frac{N_d}{n_i}\right) = 0.356 \text{ V for } N_d = 10^{16} \text{ cm}^{-3}$$

$$W_{dep} = \sqrt{\frac{2\epsilon_s(\phi_B + V_B)}{qN_d}} = 8.35 \times 10^{-5} \text{ cm for } V_R = 5 \text{ V.}$$

$$C = \frac{\epsilon_s}{W_{dep}} A = 1.25 \text{ pF} = C_{P-N \text{ jn}}$$

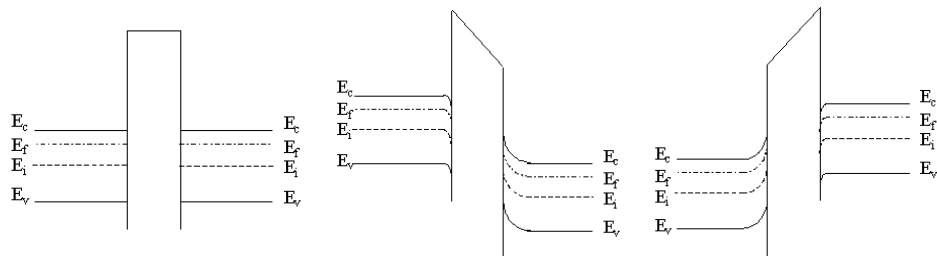
$$C_{MOS} / C_{P-N \text{ jn}} = 22.66$$

5.18 (a) The flatband voltage is 0V because the 2 silicon sides are equally doped

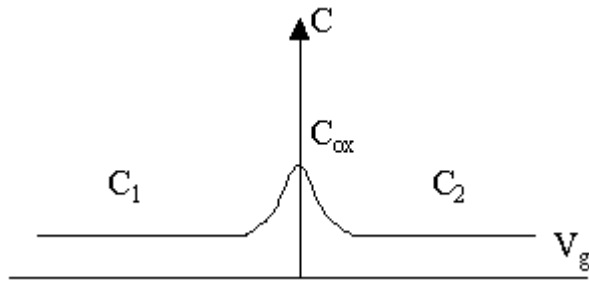
(i) $V_g = 0$

(ii) $V_g < 0$ and large

(iii) $V_g > 0$ and large



(b)



As both sides are equally doped, the values of C_1 and C_2 will be equal.

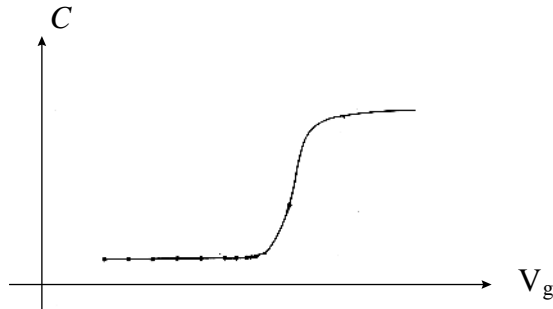
$$C_1 = C_2 = (C_{ox}^{-1} + C_{dep}^{-1})^{-1}$$

$$C_{dep} = \frac{\epsilon_s}{W_{dep}} \quad \text{where}$$

$$W_{dep} = \sqrt{\frac{2\epsilon_s}{qN_d} \frac{2kT}{q} \ln\left(\frac{N_d}{n_i}\right)} \Rightarrow C_{dep} = 34.5 \text{ nF cm}^{-2} \text{ and } C_{ox} = \frac{\epsilon_{ox}}{T_{ox}}.$$

- (c) When the left side is P-type, both the silicon layers go into accumulation and depletion for the same type of bias.

The flat band voltage will be $(\chi_{Si} + E_g/2 + \phi_{BL}) - (\chi_{Si} + E_g/2 - \phi_{BR}) = \phi_{BL} + \phi_{BR} = 0.713 \text{ V}$



5.19

Bias Condition	Surface Potential	MOS cap (LF)	MOS Cap (HF)	MOSFET
accumulation	~ 0	C_{ox}	C_{ox}	C_{ox}
flatband	$= 0$	C_{ox}	C_{ox}	C_{ox}
threshold	$= 2\phi_B$	C_{ox}	$(C_{ox}^{-1} + W_{dep,max}/\epsilon_s)^{-1}$	C_{ox}
inversion	$\sim 2\phi_B$	C_{ox}	$(C_{ox}^{-1} + W_{dep,max}/\epsilon_s)^{-1}$	C_{ox}

- 5.20** (a) Accumulation $-1 \text{ V} < V_g$
 Depletion $-3 \text{ V} < V_g < -1 \text{ V}$
 Inversion $V_g < -3 \text{ V}$
 The substrate is N-type.

(b) $C_0 = \frac{\epsilon_{ox}}{T_{ox}} A$

Thus, $T_{ox} = 205 \text{ nm}$.

(c) From the high-frequency C - V curve, $C_{min} = (C_0^{-1} + C_{dep}^{-1})^{-1}$

Plugging in $C_{min} = 0.4C_0 \Rightarrow C_{dep} = 0.67 \times C_0 = 54.9 \text{ pF}$

Now, $C_{dep} = \frac{\epsilon_s}{W_{dep}} A$

For uniform doping $W_{dep} = \sqrt{\frac{2\epsilon_s(2\phi_B)}{qN_d}}$ at threshold, where $\phi_B = \frac{kT}{q} \ln\left(\frac{N_d}{n_i}\right)$

$$\Rightarrow N_d = \frac{4\epsilon_s kT}{W_{dep}^2 q^2} \ln\left(\frac{N_d}{n_i}\right)$$

which can be solved by iteration and we get the value of $N_d \sim 10^{15} \text{ cm}^{-3}$.

(d) $V_{fb} \sim .55V + (kT/q)\ln(10^{15}/10^{10}) = .85V$

Since V_{fb} from the plot is $\sim -1V$, then Q_{ox} consists of positive charges. The shift in V_{fb} is $1.85V$. Thus,

$$Q_{ox} = 1.85V \times C_0 = 1.85V \times 82\text{pF} / 4.75 \times 10^{-3} \text{ cm}^2 = 32 \text{ nC/cm}^2.$$

Poly-gate Depletion

5.21 (a) Using Gauss Law,

$$Q_{poly} = qN_{poly}W_{dpoly} = \epsilon_{poly}\mathcal{E}_{poly} = \epsilon_{ox}\mathcal{E}_{ox},$$

where \mathcal{E}_{ox} is the electric field inside the oxide and

$$W_{dpoly} = \frac{\epsilon_{ox}\mathcal{E}_{ox}}{qN_{poly}}.$$

$$(b) \phi_{poly} = \frac{qN_{poly}W_{dpoly}^2}{2\epsilon_{poly}} = \frac{qN_{poly}}{2\epsilon_{poly}} \frac{\epsilon_{ox}^2\mathcal{E}_{ox}^2}{q^2N_{poly}^2} = \frac{\epsilon_{ox}^2\mathcal{E}_{ox}^2}{2q\epsilon_{poly}N_{poly}}.$$

$$(c) V_g = \phi_{poly} + V_{ox} + \phi_s + V_{fb}.$$

$$V_{ox}C_{ox} = |Q_s| = Q_{poly} \Rightarrow V_{ox} = \frac{1}{C_{ox}} \sqrt{2q\epsilon_{poly}N_{poly}\phi_{poly}}$$

$$V_g = \phi_{poly} + V_{fb} + \phi_s + V_{ox} = \phi_{poly} + V_{fb} + 2|\phi_B| + \frac{T_{ox}}{\epsilon_{ox}} \sqrt{2q\epsilon_{poly}N_{poly}\phi_{poly}}$$

$$\phi_{poly} + \frac{T_{ox}}{\epsilon_{ox}} \sqrt{2q\epsilon_{poly}N_{poly}} \sqrt{\phi_{poly}} - (V_g - V_{fb} - 2|\phi_B|) = 0$$

$$\begin{aligned} \sqrt{\phi_{poly}} &= \frac{-\frac{T_{ox}}{\epsilon_{ox}} \sqrt{2q\epsilon_{poly}N_{poly}} \pm \sqrt{\frac{T_{ox}^2}{\epsilon_{ox}^2} 2q\epsilon_{poly}N_{poly} + 4(V_g - V_{fb} - 2|\phi_B|)}}{2} \\ &= -\frac{T_{ox}}{2\epsilon_{ox}} \sqrt{2q\epsilon_{poly}N_{poly}} \pm \sqrt{\frac{T_{ox}^2}{4\epsilon_{ox}^2} 2q\epsilon_{poly}N_{poly} + (V_g - V_{fb} - 2|\phi_B|)} \end{aligned}$$

We know that $\sqrt{\phi_{poly}} > 0$. Also, if we set

$$\alpha = \frac{T_{ox}}{\epsilon_{ox}} \sqrt{2q\epsilon_{poly}N_{poly}} \quad \text{and} \quad \beta = (V_g - V_{fb} - 2|\phi_B|), \quad \text{then}$$

$$\sqrt{\phi_{poly}} = -\alpha + \sqrt{\alpha^2 + \beta} \quad \text{and} \quad \phi_{poly} = \beta + 2\alpha^2 \left(1 - \sqrt{1 + \frac{\beta}{\alpha^2}} \right).$$

Hence,

$$\phi_{poly} = (V_g - V_{fb} - 2|\phi_B|) + \frac{T_{ox}^2}{\epsilon_{ox}^2} q\epsilon_{poly}N_{poly} \left(1 - \sqrt{1 + \frac{2\epsilon_{ox}^2(V_g - V_{fb} - 2|\phi_B|)}{T_{ox}^2 q\epsilon_{poly}N_{poly}}} \right).$$

$$\begin{aligned} \text{(d)} \quad W_{dpoly} &= \frac{\epsilon_{ox}\epsilon_{ox}}{qN_{poly}} = \sqrt{\frac{2\epsilon_{poly}\phi_{poly}}{qN_{poly}}} = \sqrt{\frac{2\epsilon_{poly}}{qN_{poly}}} \left(-\alpha + \sqrt{\alpha^2 + \beta} \right) \\ &= \sqrt{\frac{2\epsilon_{poly}}{qN_{poly}}} \left[\sqrt{\frac{T_{ox}^2}{4\epsilon_{ox}^2} 2q\epsilon_{poly}N_{poly} + (V_g - V_{fb} - 2|\phi_B|)} - \frac{T_{ox}}{2\epsilon_{ox}} \sqrt{2q\epsilon_{poly}N_{poly}} \right]. \end{aligned}$$

(e) Using the equation derived in part (c), we find $\phi_{poly} = 0.28 \text{ V}$.

And, using the equation derived in part (d), we find $W_{dpoly} = 2.46 \text{ nm}$.

$$\left(|\phi_B| = \frac{kT}{q} \ln \left(\frac{N_a}{n_i} \right) = 0.41 \text{ V}, \quad V_{fb} = -0.97 \text{ V}, \quad \text{and} \quad \epsilon_{poly} = \epsilon_s \right).$$

(f) Calculate V_t using Equation 5.4.3:

$$V_t = V_{fb} + 2|\phi_B| + \frac{1}{C_{ox}} \sqrt{4q\epsilon_s N_a |\phi_B|} = (-0.97 + 0.82 + 0.095) \text{ V} = -0.055 \text{ V}$$

Using Equation 5.8.3 with $\phi_{poly} = 0.28 \text{ V}$,

$$Q_{inv} = C_{ox} (V_g - V_t - \phi_{poly}) = \frac{\epsilon_{ox}}{T_{ox}} (1.5 + 0.055 - 0.28) \text{ V} = 2.20 \times 10^{-6} \text{ coul} / \text{cm}^2.$$

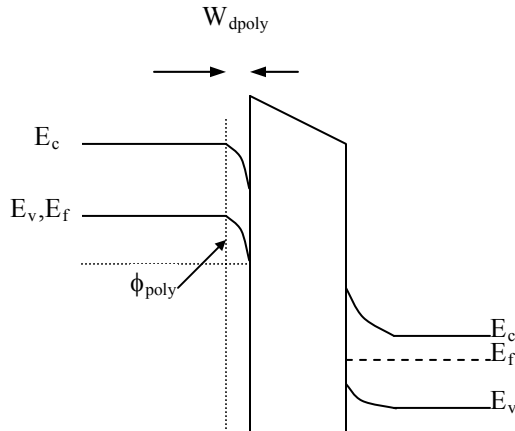
(g) First, we calculate C_{oxe} .

$$C_{oxe} = \frac{\epsilon_{ox}}{T_{ox} + W_{dpoly}/3} = 1.22 \times 10^{-6} \text{ F} / \text{cm}^2.$$

$$Q_{inv} = C_{oxe} (V_g - V_t) = 1.90 \times 10^{-6} \text{ coul} / \text{cm}^2.$$

This value is smaller than what we have found in part (f).

5.22 (a)



V_g is negative, V_{fb} is positive, ϕ_{st} is negative, V_{ox} is negative and ϕ_{poly} is negative

$$5.23 \text{ (a)} \quad Q_{poly} = qN_{poly}W_{dpoly} = qN_{poly}\sqrt{\frac{2\epsilon_s V_{poly}}{qN_{poly}}} = \sqrt{2\epsilon_s qN_{poly}V_{poly}}$$

$$(b) \quad C_{poly} = \frac{\epsilon_s}{W_{dpoly}} = \frac{\epsilon_s qN_{poly}}{Q_{poly}} = \sqrt{\frac{\epsilon_s qN_{poly}}{2V_{poly}}}$$

$$(c) \quad C_{total} = (C_{ox}^{-1} + C_{poly}^{-1})^{-1} = \left(\frac{1}{C_{ox}} + \sqrt{\frac{2V_{poly}}{\epsilon_s qN_{poly}}} \right)^{-1}$$

Threshold Voltage Expression

$$\begin{aligned} 5.24 \quad V_t &= V_{fb} + \phi_s + V_{ox} \\ &= V_{fb} + \phi_s + \frac{qN_a W_{dep}}{C_{ox}} \\ &= V_{fb} + \phi_s + \frac{\sqrt{qN_a 2\epsilon_s \phi_s}}{C_{ox}} \\ &= V_{fb} + 2\phi_B + \frac{\sqrt{qN_a 2\epsilon_s 2\phi_B}}{C_{ox}} \end{aligned}$$